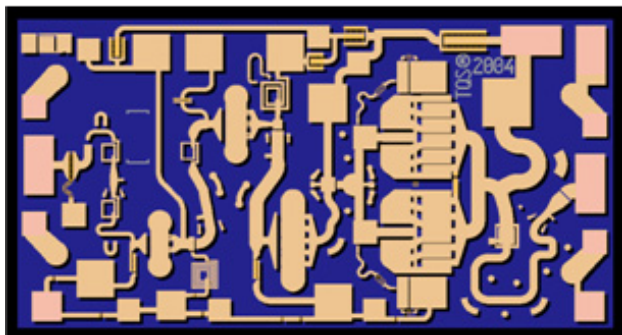


## 12-19 GHz VSAT Amplifier

## TGA2508-SCC



### Key Features

- Frequency Range: 12 - 19 GHz
- 30 dB Nominal Gain
- 30 dBm Nominal P1dB @ 15 GHz
- 32 dBm Nominal OTOI
- Bias Conditions: 7 V, 433 mA
- 0.50  $\mu$ m 3MI pHEMT Technology
- Chip Dimensions: 2.1 x 1.1 x 0.1 mm  
(0.083 x 0.118 x 0.004 in)

### Product Description

The TriQuint TGA2508 is a compact Medium Power Amplifier MMIC for VSAT applications. The part is designed using TriQuint's 0.5  $\mu$ m power pHEMT production process.

The TGA2508 provides a nominal 30 dB Gain from 12-19 GHz, with Output Power @ 1dB Gain compression of 30 dBm. The MMIC also provides 32 dBm Output TOI @ Pin/Tone = -10 dBm.

The part is ideally suited for low cost emerging markets such as VSAT Ground Terminals, Point-to-Point Radio, Military Ku Band applications.

The TGA2508 is 100% DC and RF tested on-wafer to ensure performance compliance.

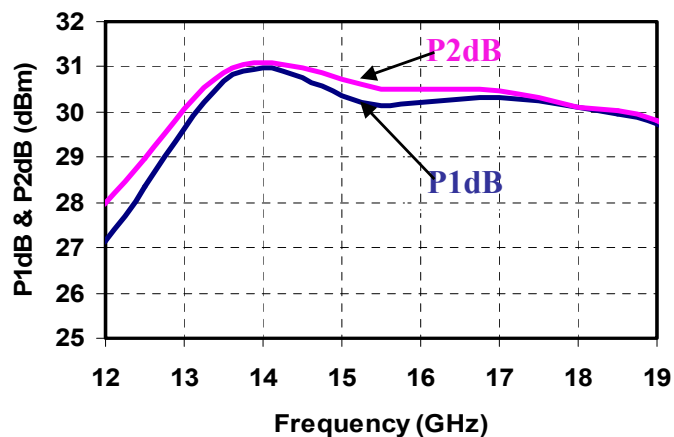
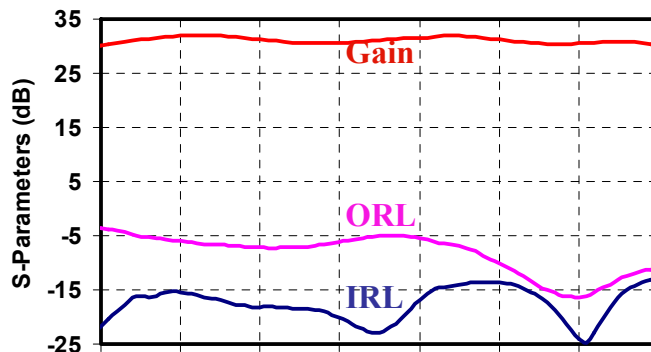
Evaluation boards are available.

### Primary Applications

- VSAT Ground Terminals
- Point to Point Radio
- Military Ku Band

### Measured Data

Bias Conditions:  $V_d = 7$  V,  $I_d = 433$  mA



**TABLE I**  
**MAXIMUM RATINGS <sup>1/</sup>**

<b>SYMBOL</b>	<b>PARAMETER</b>	<b>VALUE</b>	<b>NOTES</b>
V <sup>+</sup>	Positive Supply Voltage	8 V	<u>2/</u>
V <sup>-</sup>	Negative Supply Voltage Range	-2 to 0 V	
I <sup>+</sup>	Positive Supply Current (Quiescent)	591 mA	<u>2/ 3/</u>
I <sub>G</sub>	Gate Supply Current	16 mA	<u>3/</u>
P <sub>IN</sub>	Input Continuous Wave Power	17 dBm	
P <sub>D</sub>	Power Dissipation	5.6 W	<u>2/ 4/</u>
T <sub>CH</sub>	Operating Channel Temperature	150 °C	<u>5/ 6/</u>
T <sub>M</sub>	Mounting Temperature (30 Seconds)	320 °C	
T <sub>STG</sub>	Storage Temperature	-65 to 150 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P<sub>D</sub>.
- 3/ Total current for the entire MMIC.
- 4/ When operated at this bias condition with a base plate temperature of 70 °C, the median life is 1E+6 hrs.
- 5/ Junction operating temperature will directly affect the device median time to failure (MTTF). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 6/ These ratings apply to each individual FET

**TABLE II**  
**DC PROBE TEST**  
**(T<sub>a</sub> = 25 °C ± 5 °C)**

<b>SYMBOL</b>	<b>PARAMETER</b>	<b>MINIMUM</b>	<b>MAXIMUM</b>	<b>UNIT</b>
I <sub>DSS (Q4)</sub>	Saturated Drain Current	50	350	mA
G <sub>m (Q4)</sub>	Transconductance	200	500	mS
V <sub>p (Q1, 2, 3, 4, 5)</sub>	Pinch-off Voltage	-1.3	-0.3	V
BVGS <sub> (Q4)</sub>	Breakdown Voltage Gate-Source	-30	-8	V
BVGD <sub> (Q1-5)</sub>	Breakdown Voltage Gate-Drain	-30	-11	V

Q1 is 240um FET, Q2 is 420um FET, Q3 is 800um FET, Q4 & Q5 are 1000um FETs

**TABLE III**  
**ELECTRICAL CHARACTERISTICS**  
(Ta = 25°C ± 5°C)

PARAMETER	TYPICAL	UNITS
Frequency Range	12 - 19	GHz
Drain Voltage, Vd	7	V
Drain Current, Id	433	mA
Small Signal Gain, S21	30	dB
Input Return Loss, S11	17	dB
Output Return Loss, S22	7	dB
Output Power @ 1dB Gain compression @ 15GHz, P1dB	30	dBm
Output TOI @ Pin/Tone = -10dBm	32	dBm
Temperature Gain Coefficient	0.06	dB/°C

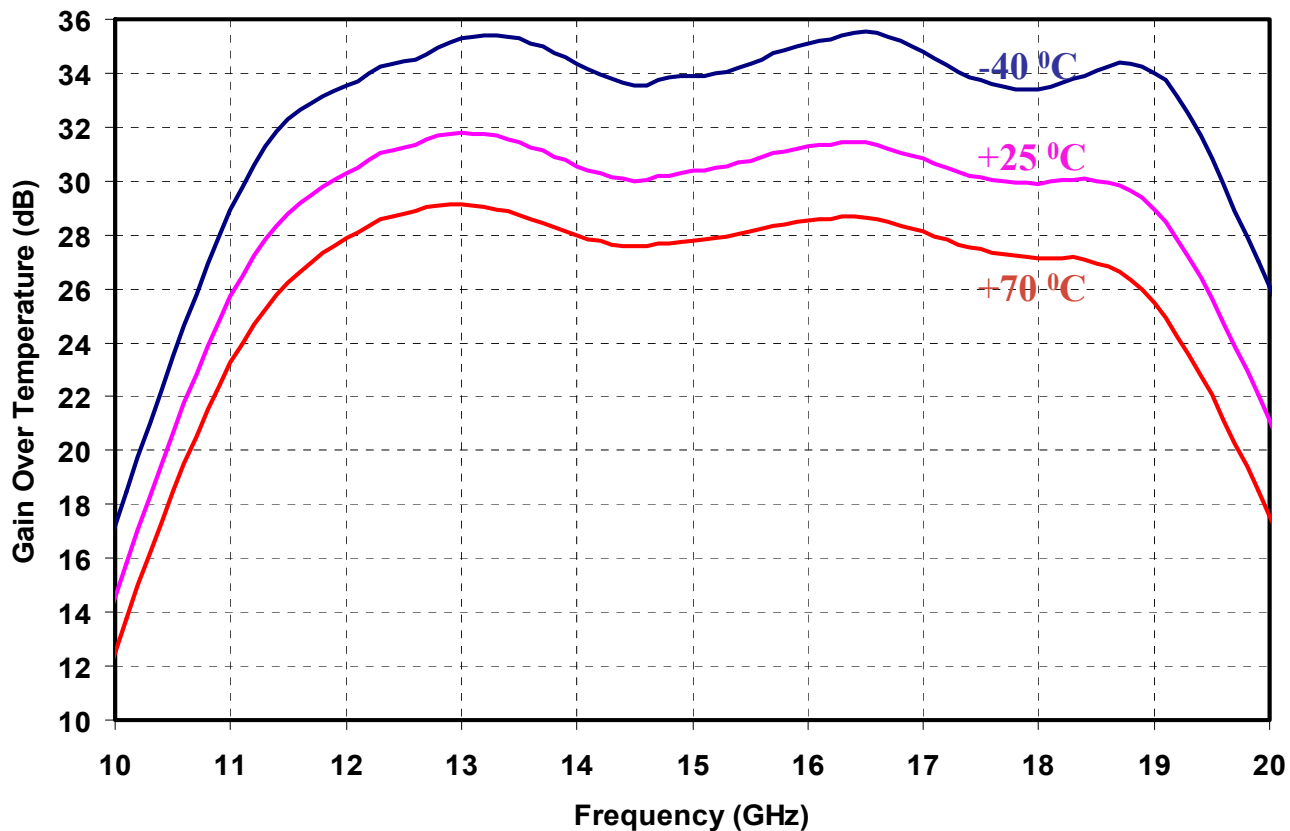
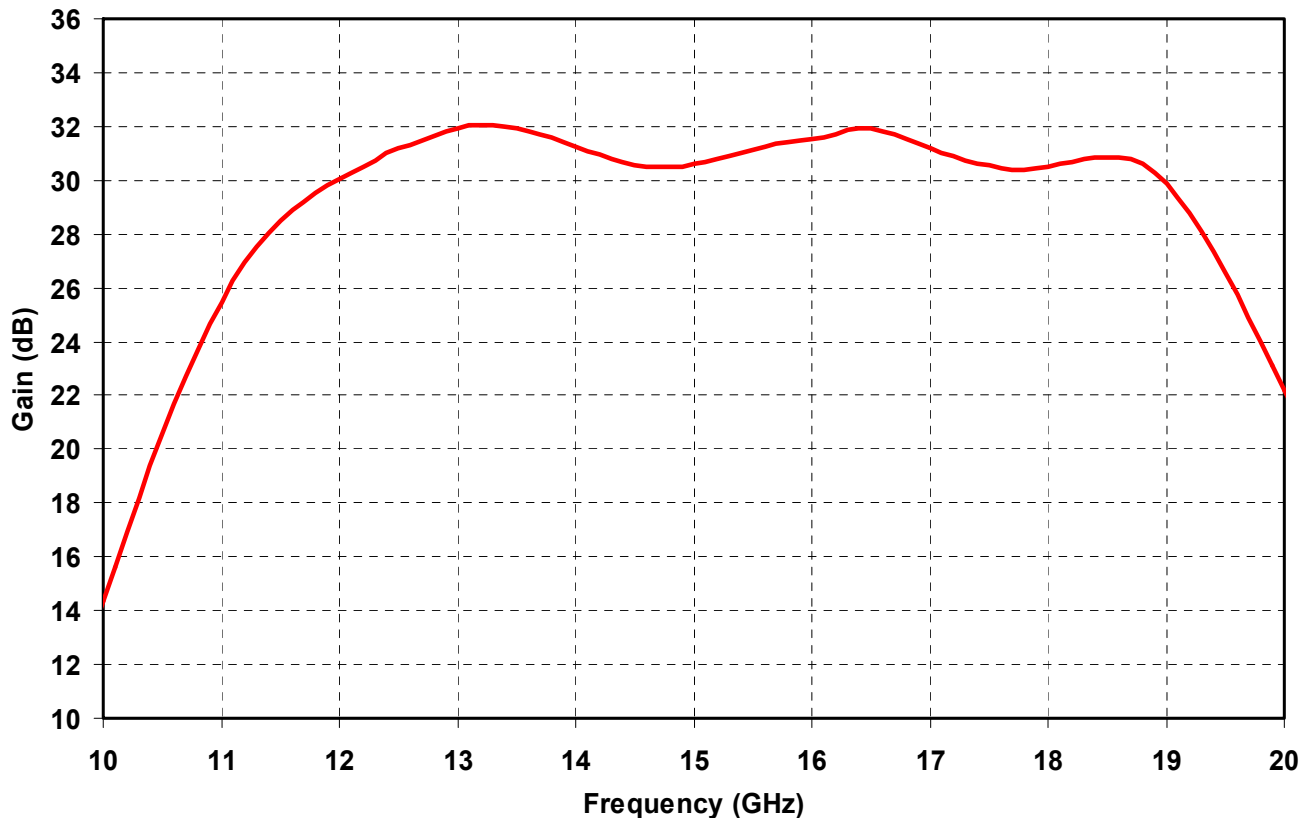
**TABLE IV**  
**THERMAL INFORMATION**

PARAMETER	TEST CONDITIONS	T <sub>CH</sub> (°C)	θ <sub>JC</sub> (°C/W)	T <sub>M</sub> (HRS)
θ <sub>JC</sub> Thermal Resistance (channel to backside of carrier)	Vd = 7 V I <sub>D</sub> = 433 mA Pdiss = 3.031 W	105.92	11.85	6.4E+7

Note: Assumes eutectic attach using 1.5 mil 80/20 AuSn mounted to a 20 mil CuMo Carrier at 70°C baseplate temperature. Worst case condition with no RF applied, 100% of DC power is dissipated.

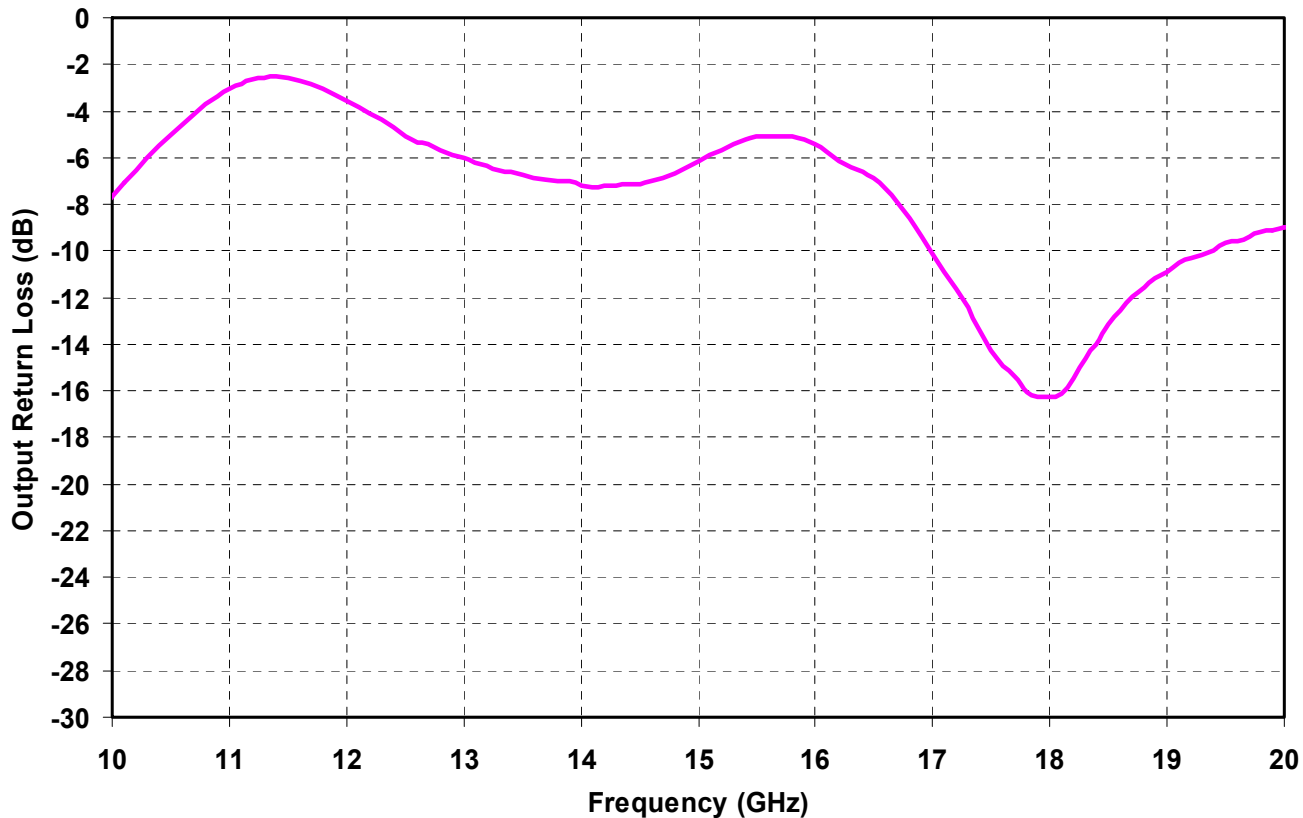
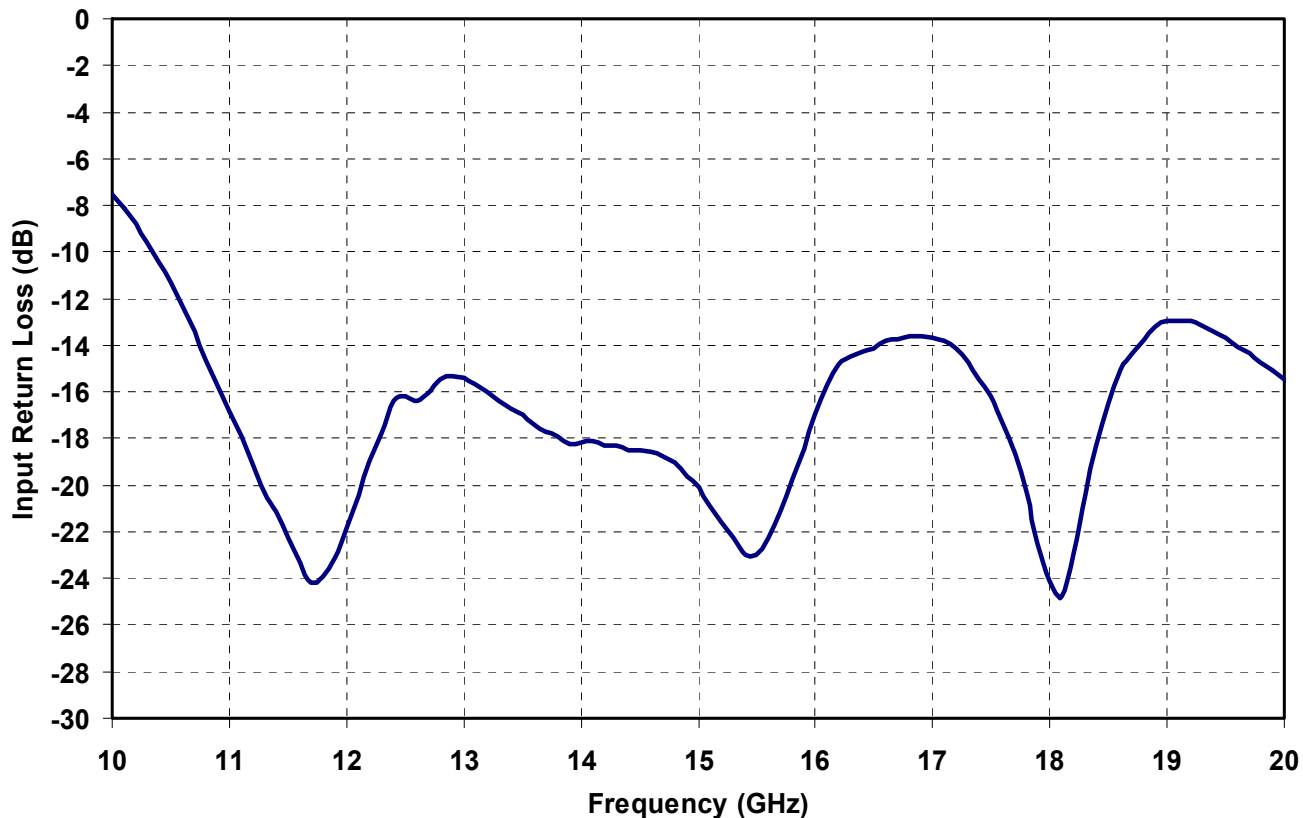
**Measured Data**

Bias Conditions:  $V_d = 7\text{ V}$ ,  $I_d = 433\text{ mA}$



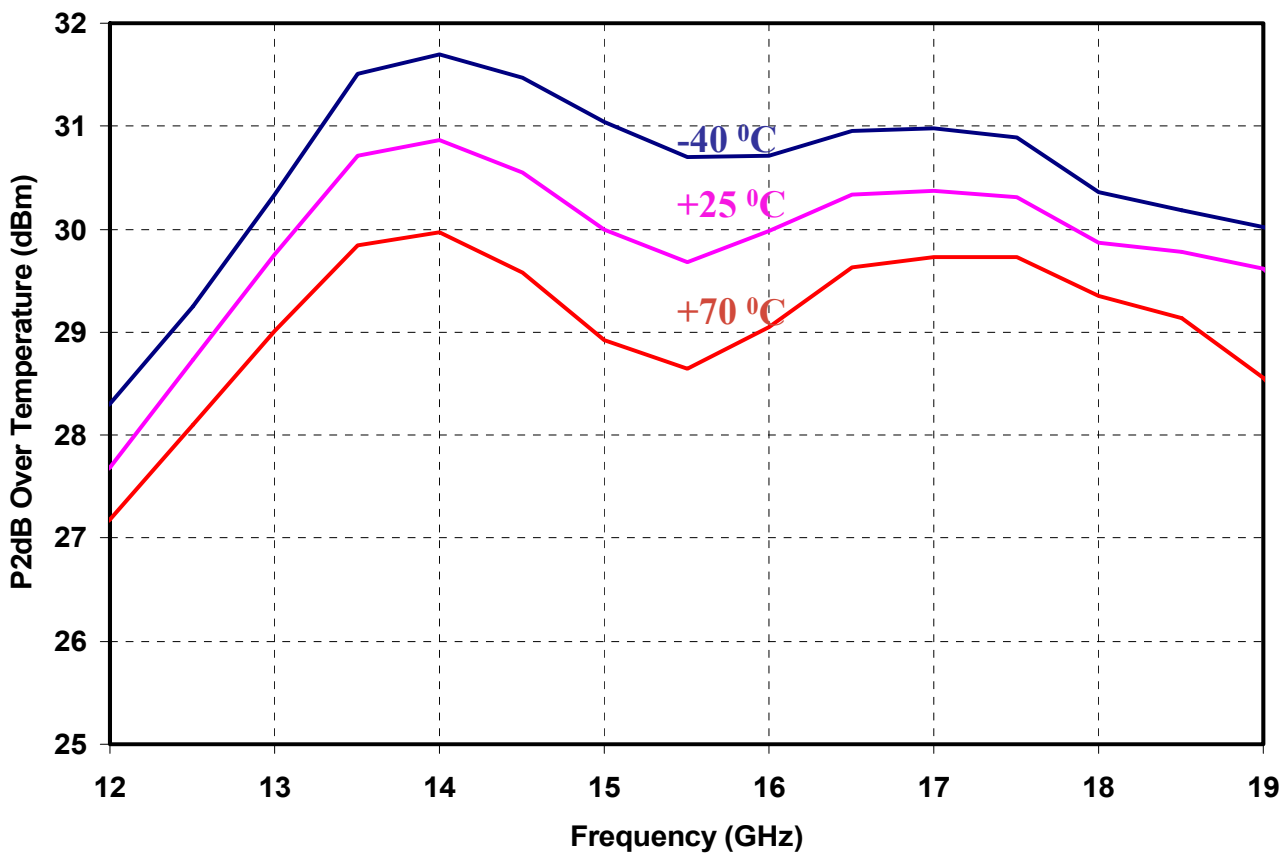
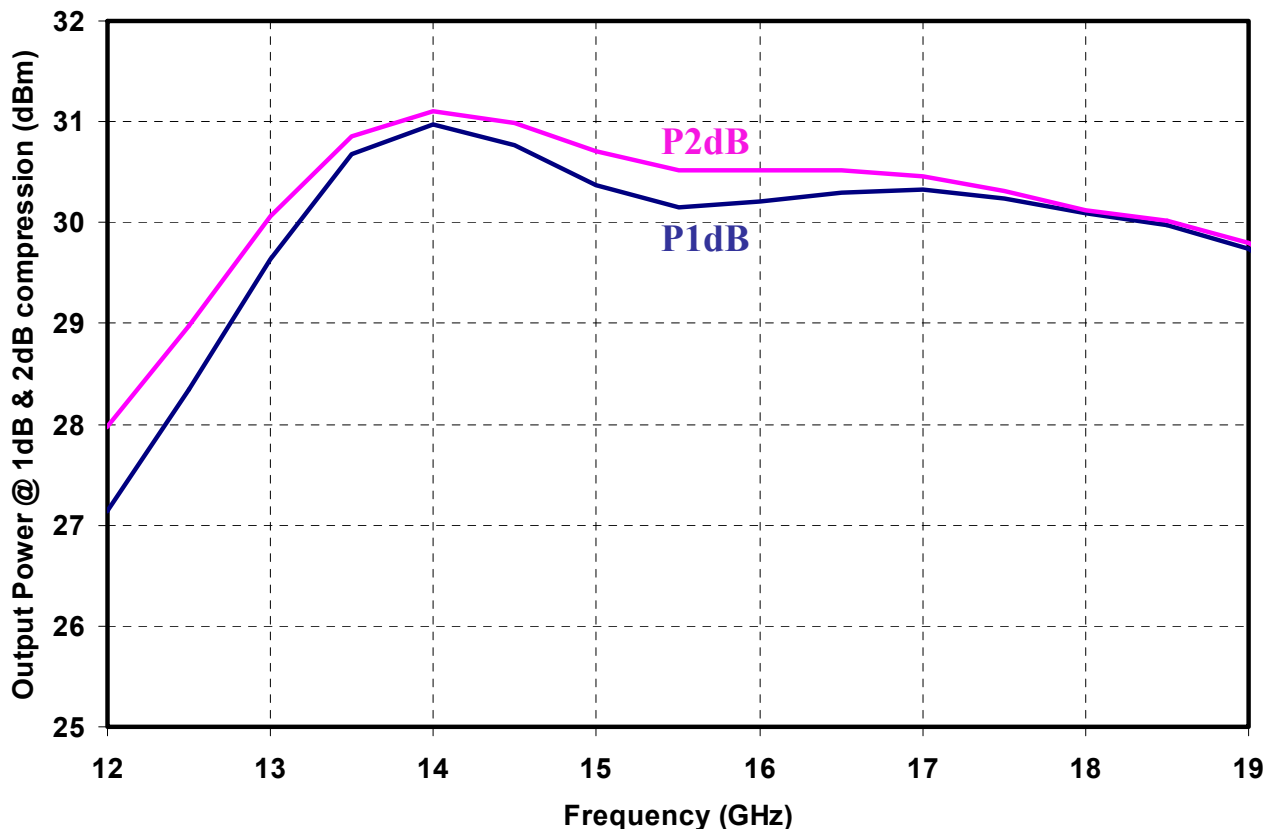
### Measured Data

Bias Conditions:  $V_d = 7\text{ V}$ ,  $I_d = 433\text{ mA}$



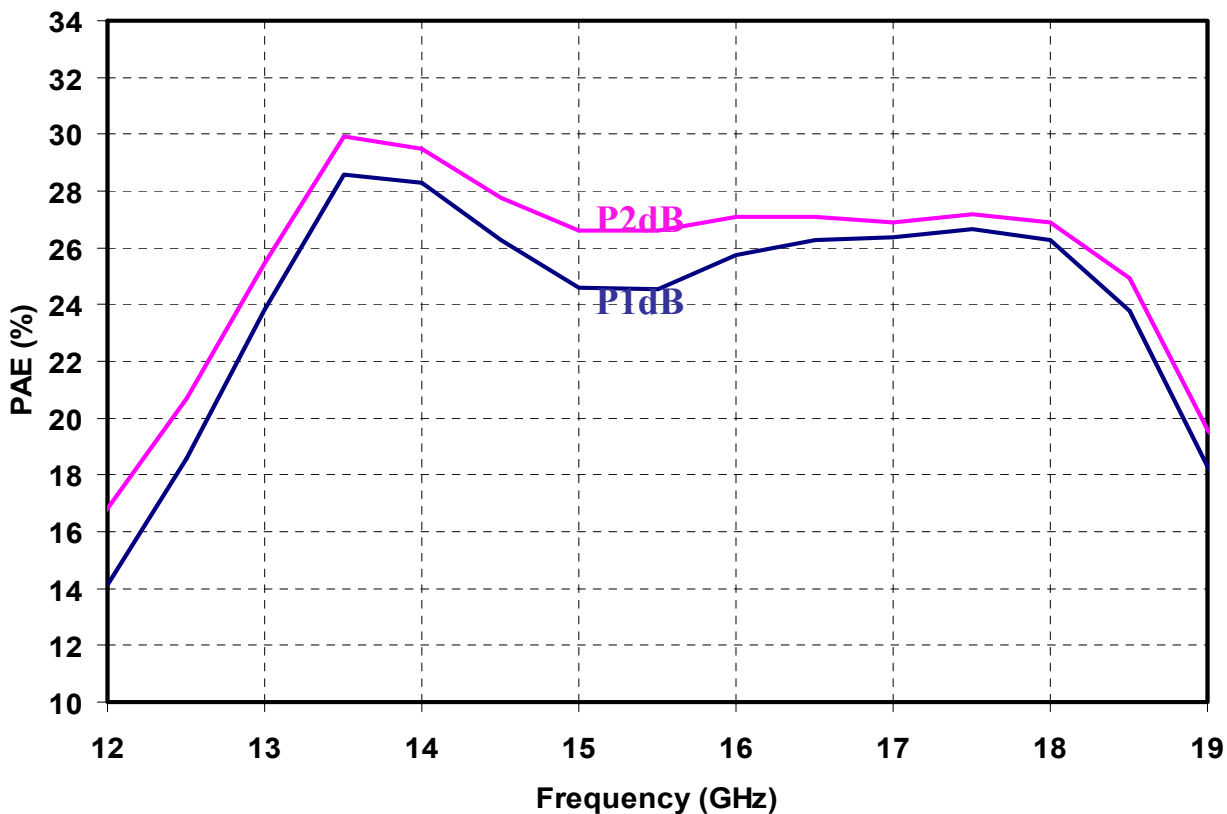
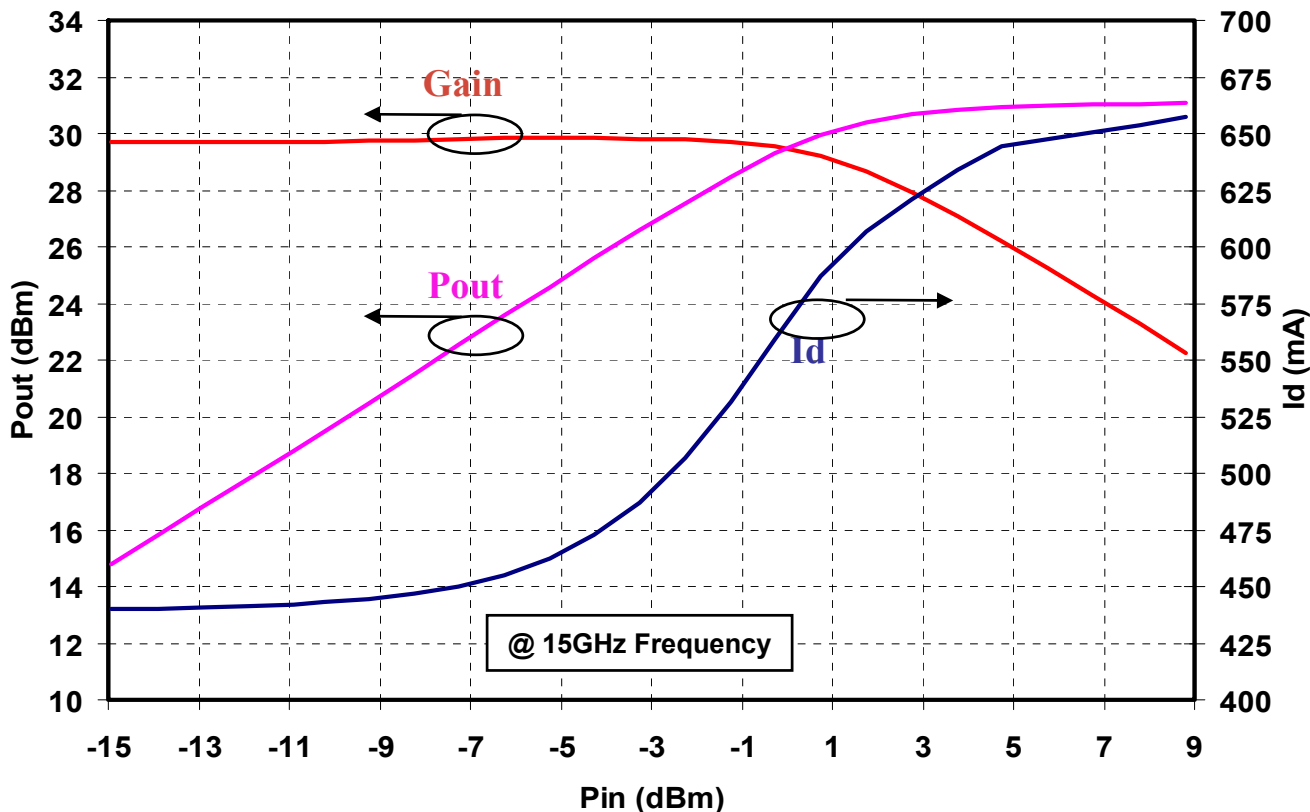
**Measured Data**

Bias Conditions:  $V_d = 7\text{ V}$ ,  $I_d = 433\text{ mA}$



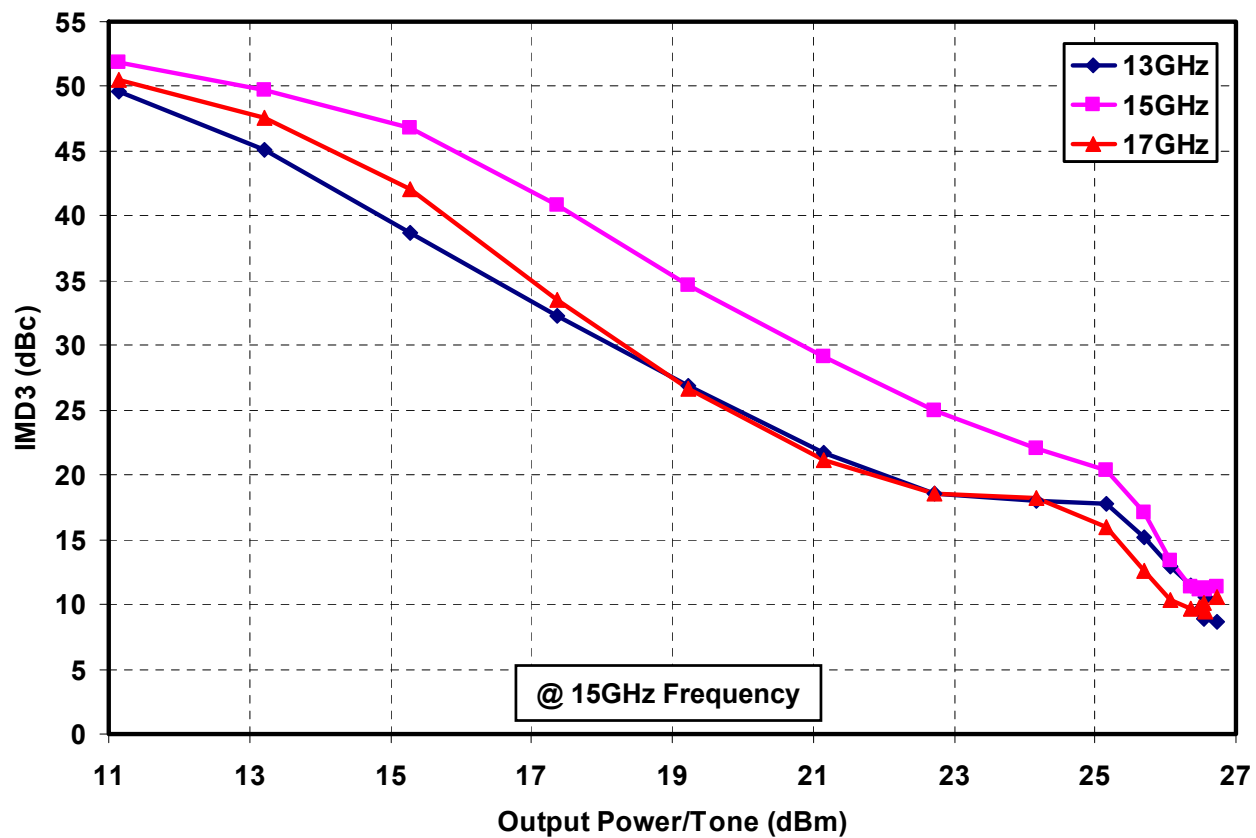
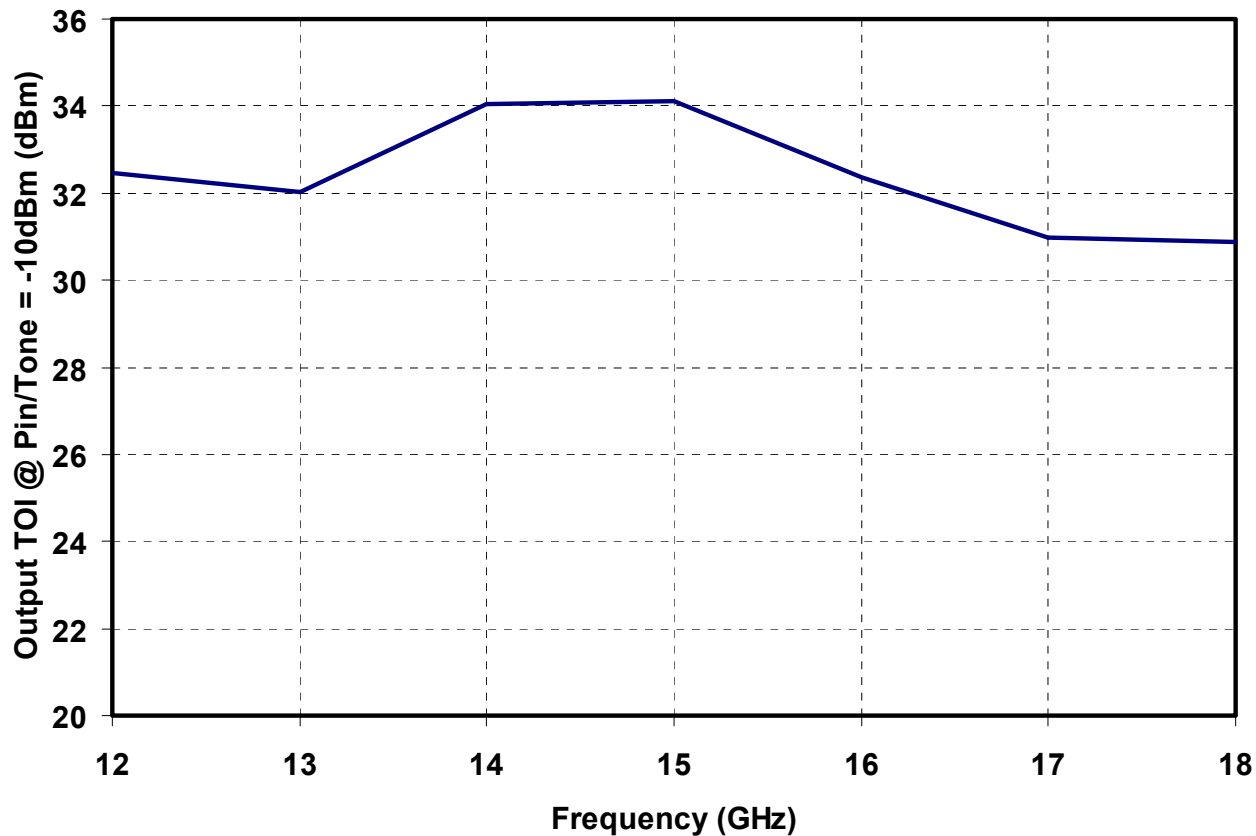
**Measured Data**

Bias Conditions:  $V_d = 7\text{ V}$ ,  $I_d = 433\text{ mA}$



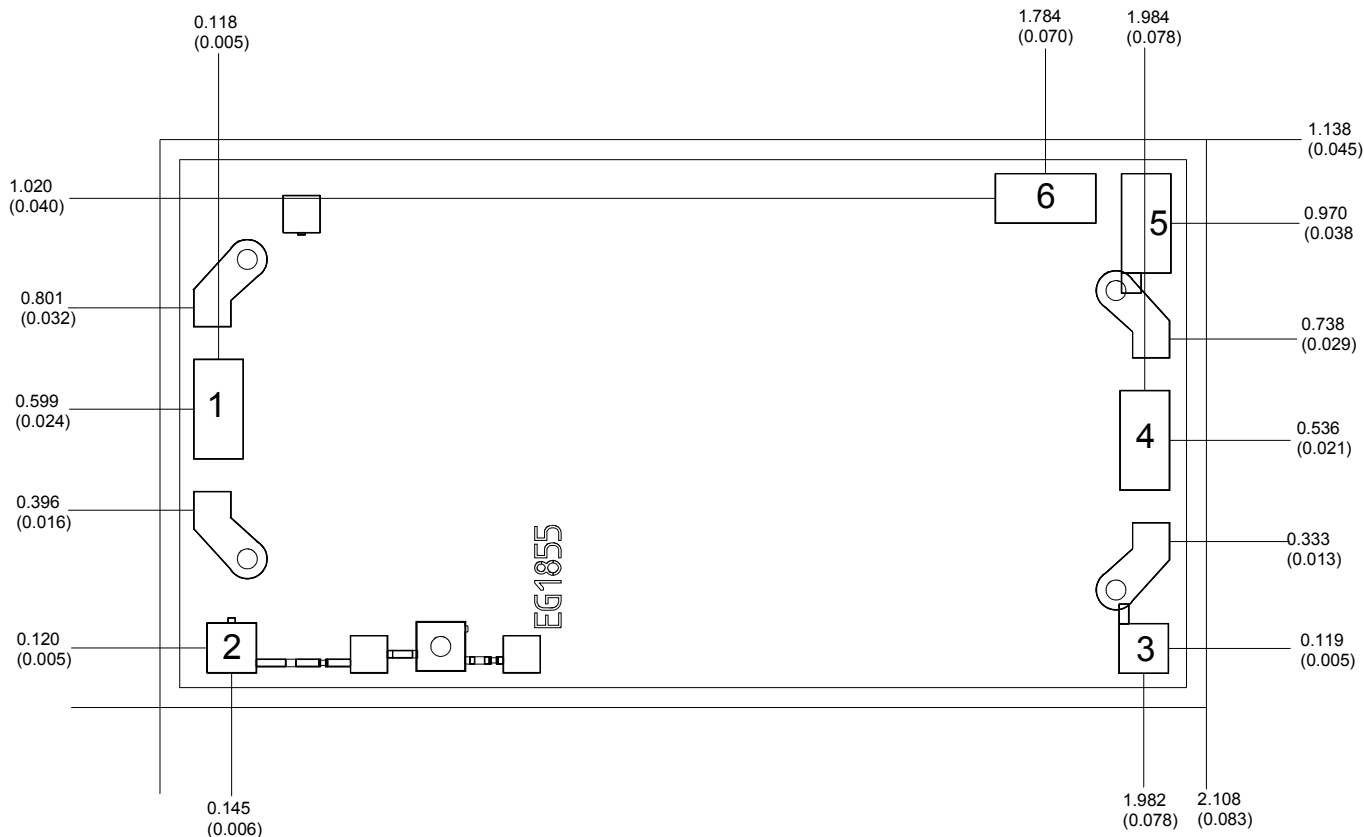
**Measured Data**

Bias Conditions:  $V_d = 7\text{ V}$ ,  $I_d = 433\text{ mA}$





**Mechanical Drawing**



Units: millimeters (inches)

Thickness: 0.100 (0.004)

Chip edge to bond pad dimensions are shown to center of bond pad

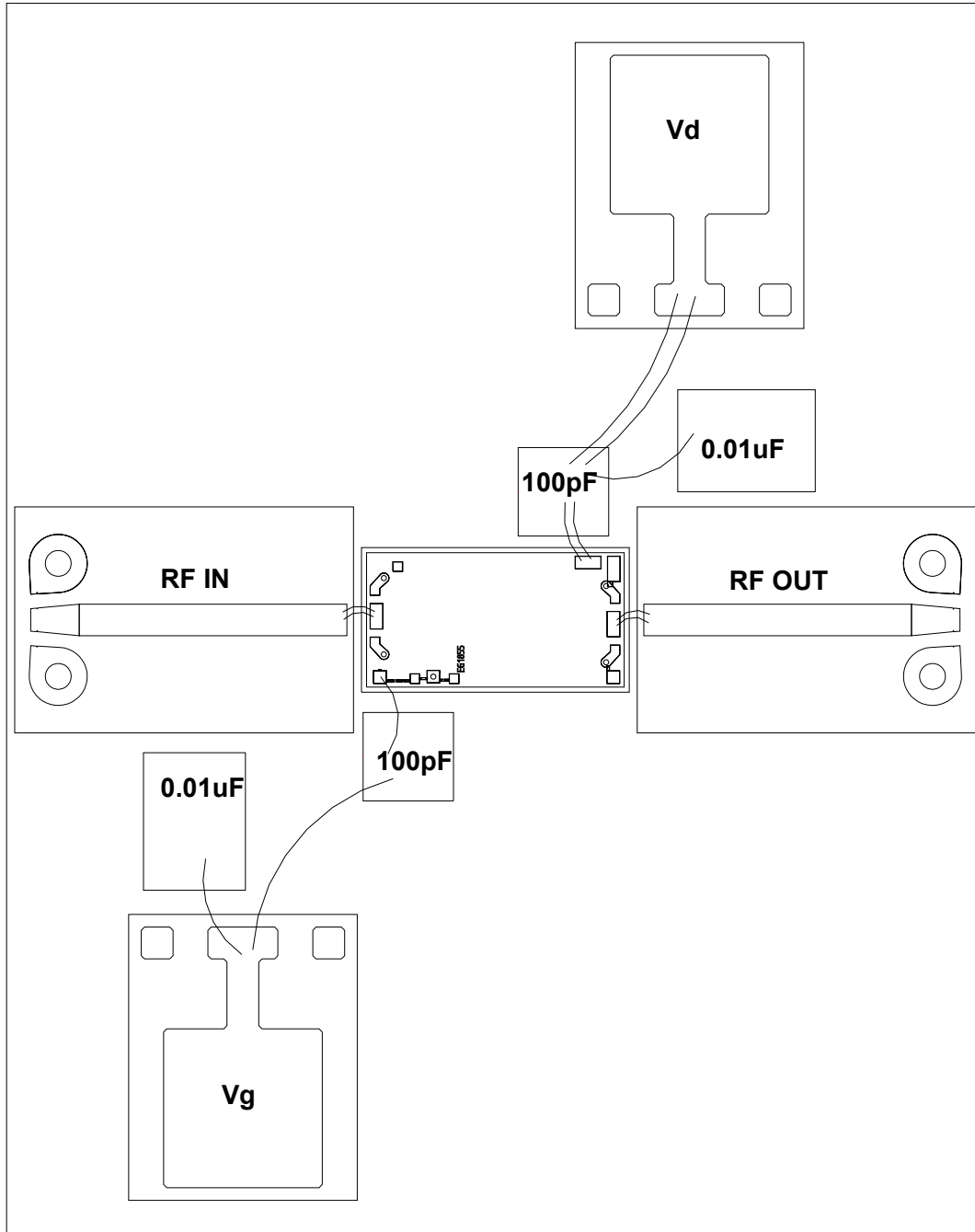
Chip size tolerance: +/- 0.051 (0.002)

Bond pad #1:	(RF In)	0.098 x 0.199	(0.004 x 0.008)
Bond pad #2:	(Vg)	0.099 x 0.099	(0.004 x 0.004)
Bond pad #3:	(DC GND)*	0.098 x 0.099	(0.004 x 0.004)
Bond pad #4:	(RF Out)	0.099 x 0.198	(0.004 x 0.008)
Bond pad #5:	(DC GND)*	0.098 x 0.198	(0.004 x 0.008)
Bond pad #6:	(Vd)	0.202 x 0.098	(0.008 x 0.004)

\* Note: RF GND is back side of MMIC.

**GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.**

### Recommended Chip Assembly Diagram



**GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.**

## **Assembly Process Notes**

Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300<sup>0</sup>C (30 seconds max).
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Maximum stage temperature is 200<sup>0</sup>C.

***GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.***